

1	BRS	L1	332	(lightwave or waveguide or substrate) and (metallic adj film) and (mask with hole) and (method or step)	PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 13:50
2	BRS	L2	84	1 and annealing	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:00
3	BRS	L3	4	1 and 385/\$.ccls.	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:01
4	BRS	L4	1	3 and annealing	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:01
5	BRS	L5	1	4 and cut\$4	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:02

	Type	L #	Hits	Search Text	DBs	Time Stamp
6	BRS	L6	4	3 and cut\$4	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:03
7	BRS	L7	6	1 and (after adj annealing)	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:54
8	BRS	L9	1	8 and annealing	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:56
9	BRS	L10	1	9 and mask	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:55
10	BRS	L11	1	10 and hole	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TD B	2003/04/15 10:55

	Type	L #	Hits	Search Text	DBs	Time Stamp
11	BRS	L12	1	11 and (metallic adj film)	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TDB	2003/04/15 10:56
12	BRS	L13	1	12 and (after adj annealing)	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TDB	2003/04/15 10:56
13	BRS	L18	12	Cutting and (divided adj waveguide)	USPAT; US-PG PUB; EPO; JPO; DERW ENT; IBM_TDB	2003/04/15 13:56